

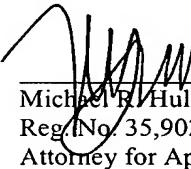


PATENT  
30205/38082

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Geun Su Lee et al. )  
Serial No.: 10/079,348 )  
Filed: February 20, 2002 )  
For: Photoresist Monomers, Polymers )  
Thereof and Photoresist Compositions )  
Containing the Same )  
Group Art Unit: 1752 )  
Examiner: Rosemary E. Ashton )  
)

I hereby certify that this paper and the  
documents referred to as enclosed  
therewith are being deposited with the  
United States Postal Service as first class  
mail, postage prepaid, on April 27, 2004,  
in an envelope addressed to  
Commissioner for Patents, P.O. Box  
1450, Alexandria, Virginia 22313-1450

  
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**AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Sir:

In response to the office action mailed on March 4, 2004, please amend  
the above-identified patent application as follows.

Amendments to the claims and a complete listing of the claims begin  
on page 2 of this paper.

Remarks begin on page 11 of this paper.